

KURT J. LESKER 'ALD/PVD/VACUUM' TECHNOLOGY WORKSHOP

March 12th – March 13th, Georgia Institute of Technology

Why Attend?

- ☐ **Expert Insights:** Gain knowledge from leading professionals in vacuum technology and thin-film deposition.
- ☐ **Live Demonstrations:** Experience live demonstrations of cutting-edge ALD and PVD equipment.
- ☐ **Networking Opportunities:** Connect with industry experts, researchers, and peers in the field.

- PVD Technologies and Sputter Process Development
- R&D on New Materials for ALD Tools
- Vacuum Science and Technology
- The Role Of Dielectric Layer In Ferroelectric Gate Stacks
- W-doped In₂O₃ Gate-All-Around Nanosheet FET
- Vanadium Dioxide-Based Metasurface Absorber
- & more topics



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IMS at Georgia Tech

The Institute for Materials and Systems (IMS) is an Interdisciplinary Research Institute at Georgia Tech dedicated to solving societal, technological, and scientific challenges by integrating knowledge across disciplines.

Contact

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